Heilmann, Rebecca; Väkeväinen, Aaro; Martikainen, J.-P.; Törmä, Päivi

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Research article

Rebecca Heilmann, Aaro I. Väkeväinen, Jani-Petri Martikainen and Päivi Törmä*

Strong coupling between organic dye molecules and lattice modes of a dielectric nanoparticle array

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Abstract: Plasmonic structures interacting with light provide electromagnetic resonances that result in a high degree of local field confinement, enabling the enhancement of light-matter interaction. Plasmonic structures typically consist of metals, which, however, suffer from very high ohmic losses and heating. High-index dielectrics, meanwhile, can serve as an alternative material due to their low-dissipative nature and strong scattering abilities. We studied the optical properties of a system composed of all-dielectric nanoparticle arrays covered with a film of organic dye molecules (IR-792) and compared these dielectric arrays with metallic nanoparticle arrays. We tuned the light-matter interaction by changing the concentration in the dye film and reported the system to be in the strong coupling regime. We observed a Rabi splitting between the surface lattice resonances of the nanoparticle arrays and the absorption line of the dye molecules of up to 253 and 293 meV, for the dielectric and metallic nanoparticles, respectively. The Rabi splitting depends linearly on the square root of the dye molecule concentration, and we further assessed how the Rabi splitting depends on the film thickness for a low dye molecule concentration. For thinner films of thicknesses up to 260 nm, we observed no visible Rabi splitting. However, a Rabi splitting evolved at thicknesses from 540 to 990 nm. We performed finite-difference time-domain simulations to analyze the near-field enhancements for the dielectric and metallic nanoparticle arrays. The electric fields were enhanced by a factor of 1200 and 400, close to the particles for gold and amorphous silicon, respectively, and the modes extended over half a micron around the particles for both materials.

Keywords: strong coupling; dielectric nanoparticle arrays; Rabi splitting; organic dye molecules; surface lattice resonances.

1 Introduction

If an emitter and an optical mode of its local environment are coupled to each other and exchange energy, hybrid states of the original modes can arise for a sufficiently strong coupling. A system is in the strong coupling regime when the coupling, or Rabi splitting, exceeds the linewidth of the hybrid modes.

Strong coupling has been observed between single emitters and high-quality cavity modes, and in various other systems; for a brief review, see the introduction of Ref. [1]. In this work, we focus on strong coupling in the context of plasmonics [1], where the strong coupling typically involves ensembles of emitters, although the single-emitter regime has been approached as well [2]. For ensembles of emitters, the Rabi splitting is, in general, proportional to the square root of their concentration. In the strong coupling regime of plasmonic systems, coherence phenomena can be observed [3, 4]. Plasmonic systems in the strong coupling regime have been reported to form polariton lasers and condensates [5], exhibit enhanced conductivity [6], and demonstrate efficient second harmonic generation [7]. Light strongly coupled to molecular transitions has also been reported to alter chemical reactions [8, 9].

An interesting plasmonic system where strong coupling has been observed and utilized are metal nanoparticle arrays. In these arrays, the localized plasmonic resonances of the nanoparticles hybridize with diffracted orders of the periodic structure, forming lattice modes called surface lattice resonances (SLRs) [10–12]. The SLR modes couple to the absorption line of emitters, for example organic dye molecules, and reach the strong coupling regime as evidenced by the square root dependence
of the Rabi splitting on the emitter concentration, as reported by Väkeväinen et al. [13]. Strong coupling in such arrays has already led to new coherence, lasing, and condensation phenomena [4, 5, 14, 15].

For the further exploitation of strong coupling in nanoparticle arrays, it would be desirable to increase the lifetime of the system, and eventually make them complementary metal-oxide-semiconductor (CMOS) compatible for integration with present microelectronic components. The metal nanoparticles have a major drawback: high absorption losses that lead to broad resonances and short lifetimes. High-index dielectric materials, meanwhile, offer low-dissipative properties and provide not only electric but also magnetic resonances due to the excitation of circular displacement currents inside the material [16].

Many plasmonic effects observed in metallic materials can be realized with high-index dielectric materials. Optimally induced resonances have been realized with different shapes of dielectric nanoparticles, such as spheres, spheroids, disks, rings, and cylinders [17]. Dielectric nanoparticle arrays have resonances analogous to the localized surface plasmon resonances and diffracted orders, which form SLRs similar to those observed in metallic nanoparticle arrays [18].

Silicon, in particular, has advantages such as its well-established fabrication technologies, CMOS compatibility, and the possibility to integrate it into existing silicon optics, as well as being low-cost compared to traditional plasmonic materials such as gold or silver [16]. In addition, silicon nanoparticles are promising candidates for spectroscopic measurements close to the particles due to their low heat generation [19]. Strong coupling in silicon nanostructures has been predicted theoretically between J-aggregates and silicon nanoparticles [20] and demonstrated experimentally in similar structures [21], as well as in systems of J-aggregates and silicon nanodisks [22, 23].

In this work, we explored the strong coupling phenomena in dielectric nanoparticle arrays. The cylindrical nanoparticles consist of amorphous silicon and are arranged in square lattices. Organic dye molecules (IR-792) act as emitters. Transmission measurements were conducted with the amorphous silicon nanoarrays, and, for comparison, with similar gold nanoarrays. The concentration of the dye molecules was varied and the Rabi splitting extracted. To further investigate differences between amorphous silicon and gold nanostructures, we performed finite-difference time-domain (FDTD) simulations using commercially available software [24]. We found strong coupling between the SLRs of dielectric nanoarrays and the absorption line of the emitters.

We observed an increase in the Rabi splitting with the square root of the dye concentration. The amorphous silicon and gold nanoparticle arrays showed similar Rabi splittings of 253 and 293 meV, respectively. This makes amorphous silicon nanoparticle arrays useful for applications as metal nanoparticle arrays.

2 Materials and methods

We fabricated arrays of cylindrical gold and amorphous silicon nanoparticles. The gold nanocylinders had a diameter of 100 nm and a height of 50 nm arranged in a square lattice, while the amorphous silicon nanocylinders had a diameter of 100 nm and a height of 100 nm with the same lattice dimensions. In both cases, the lattice periodicities were varied in 10-nm steps from 580 to 610 nm in x- and y-directions. Figure 1A shows a scanning electron microscope (SEM Zeiss Supra 40, Carl Zeiss AG, Jena, Germany) picture of an amorphous silicon nanoarray.

The samples were fabricated on borosilicate substrates with electron-beam lithography (Vistec EPBG5000pES, Vistec Electron Beam GmbH, Jena, Germany). To fabricate the gold samples, a resist layer of polymethyl methacrylate (PMMA) A4 (950 PMMA A series by MicroChem, Westborough, MA, USA) was spin-coated onto the substrate and 10 nm of aluminum was evaporated (Evaporator MASA, Instrumentti Mattila, Mynämäki, Finland) on top of the resist to obtain a conductive layer for the electron beam exposure. The layout for the nanoparticle arrays was patterned into the resist. The aluminum layer was etched in AZ 351 B, and the resist was developed in an IPA:MIBK (1:3) solution. After this, 2 nm of titanium and 50 nm of gold were evaporated onto the sample, and a lift off was carried out in acetone. The titanium layer is necessary to enhance the adhesion between the substrate and gold.

For the fabrication of the amorphous silicon samples, 100 nm of amorphous silicon was deposited onto the substrate with chemical vapor deposition (PECVD Plasmalab 80Plus Oxford Instruments, Abingdon, UK). Following this, chromium nanoarrays were fabricated on top of the amorphous silicon similarly to the gold nanoparticles. These chromium nanoarrays serve as masks for the etching of amorphous silicon via reactive ion etching (RIE Plasmalab 80Plus Oxford Instruments, Abingdon, UK). The reactive ion etching was conducted at a power of 200 W, a pressure of 10 mTorr, with a SF$_6$ flow of 15 sccm and a CHF$_3$ flow of 50 sccm for 5 min. The chromium mask was etched off afterwards in chromium wet etchant, so that only the amorphous silicon nanoarrays were left on the sample.

The IR-792 molecules were dissolved into PMMA A3 (3% PMMA in anisole) with different concentrations and spin-coated onto the samples at 3000 rpm for 1 min, which...
gave rise to a film thickness of approximately 150 nm. The arrays were embedded in a symmetric refractive index environment by immersion in index-matching oil and addition of another borosilicate slide on top ($n = 1.52$).

Different film thicknesses of the dye films were obtained by changing the viscosity of the PMMA mixture and varying the spin-coating speed. The higher the amount of PMMA, the more viscous the mixture became. The dye molecules were dissolved into PMMA-anisole mixtures with 3% and 6% PMMA in anisole and spin-coated with speeds of 1000, 2000, and 3000 rpm. The film thicknesses were measured with a profilometer (Bruker Dektak/XT, Bruker, Karlsruhe, Germany). All chemicals and dye molecules mentioned were purchased from Sigma-Aldrich (St. Louis, MO, USA).

The transmission measurement setup is depicted in Figure 1B. The sample is illuminated by a white light source, collected by a 0.3 numerical aperture objective (Nikon Plan Fluor, Nikon, Tokyo, Japan) and guided to a spectrometer (Princeton Instruments IsoPlane SCT 320, Princeton Instruments, Trenton, NJ, USA). The light excites in-plane propagating modes in $k_x$ - and $k_y$-directions, each of which have two polarization components. The modes with the E-field polarized perpendicular and parallel to the propagation direction are transverse electric (TE) and transverse magnetic (TM) modes, respectively. With the spectrometer, we only recorded the modes propagating in $k_y$-direction and a linear polarizer was used to filter out the TM modes. Hence, only the TE modes are visible in the measured extinction spectra.

To characterize the Rabi splitting between the SLR and the absorption line of the dye, we fitted a coupled-mode model to the measured extinction spectra. First, a three-coupled-modes model was used to obtain the SLRs of the arrays without the dye. The modes involved were the localized surface plasmon resonances and the two diffracted orders. As only the upper branches, i.e. the modes above the diffracted-order crossing, were involved in the coupling, it was sufficient to only take these into consideration. After obtaining the SLRs of the bare arrays, a two-coupled-modes model containing the SLRs and the main absorption peak of the IR-792 was fitted to the measured extinction spectra. The coupled-modes model between the SLRs and the main absorption peak of the IR-792 is given by the following matrix:

$$
M = \begin{pmatrix}
E_{\text{SLR}} - i\gamma_{\text{SLR}} & s \\
\Omega / 2 & E_{\text{abs}} - i\gamma_{\text{abs}}
\end{pmatrix},
$$

where $E$ and $\gamma$ are the energies and line widths of the uncoupled modes, respectively, and $\Omega$ is the Rabi splitting. In addition, we introduced a constant shift, $s$, to
account for a shift in the refractive index introduced by the dye molecule film. Here, the modes of the coupled system are given by the eigenvalues of the matrix. We extracted the peaks of the SLRs in the measured extinction spectra for each $k$ and applied a least-square-sum model to minimize the difference between the eigenvalues of the matrix and the extracted peaks from the measurements. Here, $\Omega$ and $s$ are used as fitting parameters. Figure 1C shows the absorption spectrum of IR-792 at a concentration of 100 mm. The absorption spectra at the other concentrations used are shown in Supplementary Material, Figure 2.

The optical properties of the dielectric and gold nanoarrays were studied with the FDTD method by using commercially available software (Lumerical FDTD Solutions, Lumerical Inc., Vancouver, BC, Canada) [24]. The arrays consisted of cylinders in diameter and height as in the experiments. The refractive indices for gold [“Au(Gold)-CRC”] and titanium [“Ti(Titanium)-CRC”] were used from the material database provided by Lumerical, which are based on the CRC Handbook of Chemistry and Physics [25]. The refractive index for amorphous silicon was added as a custom-made material according to the CRC Handbook of Chemistry and Physics [26]. The background refractive index was set to 1.52. To simulate the array, periodic boundary conditions were used around the unit cell with perfectly matched layers rays, as described in Section 2. The Rabi splitting is calculated for gold and amorphous silicon arrays with periodicities ranging from 580 to 610 nm in 10-nm steps. Sufficiently away from the single particle resonance, the SLR modes for different periodicities have similar density of states and thus couple in the same way with the molecules. Therefore, we can use the standard deviation of the values obtained for different periodicities, at the same concentrations, in estimating the error limits for the Rabi splitting.

The strong coupling condition in the case of two modes with finite linewidths is given by $\Omega > \frac{\gamma_{\text{dye}} + \gamma_{\text{SLR}}}{2}$, where $\Omega$ is the Rabi splitting and $\gamma_{\text{dye}}$ and $\gamma_{\text{SLR}}$ are the linewidths of the uncoupled dye molecules and SLRs, respectively [1]. It is evident from Figure 2A that the uncoupled SLR width stays constant for all $k$. The value for $\gamma_{\text{SLR}}$ was calculated to be 10 meV for both amorphous silicon and gold, as obtained by taking a crosscut at $k = 0.5 \mu m^{-1}$. To obtain $\gamma_{\text{dye}}$, the sum of two Gaussians is fitted to the measured absorption spectra of the dye for each concentration. From this fit, the full width at half maximum of the main absorption peak is extracted. The obtained values for $\Omega$ and $\gamma_{\text{dye}}$ are listed in Table 1. The dye linewidth can be alternatively determined by fitting one Gaussian to the absorption spectra (see corresponding results in the Supplementary Material, Table 1 and Figure 3). While the numerical values of the Rabi splitting and the linewidths are slightly changed, the qualitative behavior is the same. The strong coupling condition is met for all concentrations except 25 mm. Therefore, and as there is no visible splitting for a concentration of 25 mm (see Figure 2C), it is concluded that the system with such a low concentration is not in the strong coupling regime (splitting below the linewidth). Hence, we excluded this particular data point in Figure 3A.

Figure 3A shows the Rabi splitting as a function of the square root of the molecular concentration, $\sqrt{C}$, and a linear dependence is clearly evident. Both systems, gold and emitters as well as amorphous silicon and emitters, are in the strong coupling regime. In general, the Rabi splitting is larger for the gold than for the amorphous silicon nanoparticle arrays.

Now, one has to keep in mind that rather thin films were used for the above results. If the film covers the
Figure 2: Measured extinction spectra in k-space.
Dispersion measurements of a nanoarray of amorphous silicon nanoparticles with a periodicity of 600 nm in x- and y-directions, diameter of 100 nm, and dye concentrations of (A) 0 mM, (C) 25 mM, (D) 50 mM, (E) 75 mM, (F) 100 mM, (G) 150 mM, and (H) 200 mM. The film thickness is 150 nm. Maximum extinction is given in yellow. (B) Shows a crosscut through (A) at \( k_y = 0 \). In (A), the red dashed lines depict the uncoupled diffracted orders of the lattice and the black solid lines the SLRs obtained by the coupled mode fitting of the extinction maxima. In (C–H), the horizontal red dashed line depicts the absorption line of the dye molecules and the diagonal red lines correspond to the fitted SLRs (upper branch) from (A). The solid black lines depict the coupled-modes fitting of the extinction maxima. It is clearly visible that the Rabi splitting increases with increasing dye molecule concentration.
whole mode volume of the plasmonic system, then the concentration determines the Rabi splitting. However, if the mode volume extends beyond the film thickness, then by increasing the thickness, one introduces more emitters into the mode volume and the Rabi splitting may increase with the film thickness also for the same concentration. Therefore, by varying the film thickness, one can obtain indirect information about the extent of the mode volume, which is, in general, a difficult question to address in plasmonics [27, 28].

To investigate this issue, we measured different dye layer thicknesses with 25 mm dye concentration, as shown in Figure 3B. With thicker dye layers, the system evolves into the strong coupling regime. It is clear that the splitting increases with the dye layer thickness, suggesting that the amount of emitters participating in the interaction with the SLR increases. The Rabi splitting arises for a 530-nm-thick dye layer, but its size does not increase much when increasing the layer thickness further. The saturation of the Rabi splitting as a function of dye layer thickness implies that the SLR mode volume, despite having high field enhancement near the nanoparticles, reaches to some extent up to 700 nm from the array plane. It has been predicted theoretically [29] and observed in silver hole arrays coupled to CdSe nanoplatelets [30] that the Rabi splitting first increases linearly and then saturates with increasing film thickness. The surface plasmon polariton modes decay exponentially from the metal, and additional emitters cannot couple to the modes beyond the confinement length. As the amorphous silicon particles show, in general, similar results as the gold particles, we conclude that the modes in the dielectric nanoparticle arrays behave similarly to the modes of the metal nanoparticle structures.

Table 1: Measured linewidth of the dye molecules, γ _dye_, the strong coupling condition, (γ _dye_ + γ SLR)/2, and Rabi splittings of amorphous silicon and gold, Ω _a–Si_ and Ω _Au_, for different concentrations, c, for a film thickness of 150 nm.

<table>
<thead>
<tr>
<th>c (mm)</th>
<th>γ <em>dye</em> (eV)</th>
<th>(γ <em>dye</em> + γ SLR)/2 (eV)</th>
<th>Ω <em>a–Si</em> (eV)</th>
<th>Ω <em>Au</em> (eV)</th>
</tr>
</thead>
<tbody>
<tr>
<td>25</td>
<td>0.10</td>
<td>0.06</td>
<td>–</td>
<td>–</td>
</tr>
<tr>
<td>50</td>
<td>0.11</td>
<td>0.06</td>
<td>0.13</td>
<td>0.13</td>
</tr>
<tr>
<td>75</td>
<td>0.12</td>
<td>0.07</td>
<td>0.16</td>
<td>0.19</td>
</tr>
<tr>
<td>100</td>
<td>0.11</td>
<td>0.06</td>
<td>0.17</td>
<td>0.20</td>
</tr>
<tr>
<td>150</td>
<td>0.12</td>
<td>0.07</td>
<td>0.21</td>
<td>0.23</td>
</tr>
<tr>
<td>200</td>
<td>0.13</td>
<td>0.07</td>
<td>0.25</td>
<td>0.29</td>
</tr>
</tbody>
</table>

The molecule linewidth is obtained by fitting two Gaussians to the measured absorption spectrum (see Figure 1) and choosing the underlying Gaussian for the main absorption peak.

In (A), the data point at c = 25 mm is excluded, as the splitting is smaller than the linewidth and thus not measurable.

Figure 3: Dependence of the Rabi splitting on the square root of the concentration √c for a film thickness of 150 nm (A) and Rabi splitting for c = 25 mm as a function of different film thicknesses (B).

Figure 4B and 5B show the measured extinction spectra
for comparison to the simulations. In the case of amorphous silicon, the measured SLRs are located at 914 and 654 nm. For gold, the first SLR is located at 913 nm. The second SLR overlaps with the single particle resonance, which is at 691 nm. In general, the simulations and measurements agree very well.

The local electric field intensity for the amorphous silicon is enhanced by a factor of 400 for the first SLR and by a factor of 80 for the second SLR. In the case of gold, the local electric field is enhanced by a factor of 1200 for the first SLR and by a factor of 70 close to the second SLR at 690 nm. The field enhancements are therefore larger for gold than for amorphous silicon for this set of parameters. Note that it is difficult to compare the field enhancement systematically, as particles that are of the same size but made of different materials will have their single particle resonances at different energies. Nonetheless, the difference in the near-field enhancement is probably the reason for the larger values for the Rabi splitting in case of the gold nanoparticle arrays.

Figure 4: FDTD simulation results for amorphous silicon. (A) Simulated transmission spectrum and (B) measured spectra at $k_z = 0$ for comparison. Electric field intensity distribution at resonance at 646 nm crosscuts in the $xy$-plane (C) and $xz$-plane (D). Electric field intensity distribution at resonance at 913 nm crosscuts in the $xy$-plane (E) and $xz$-plane (F).
The crosscuts through the electric field magnitude in the xy-plane (see Figures 4C,E and 5C,E) and yz-plane (see Figures 4D,F and 5D,F) are shown in a 1.2-μm range around the particle. In the case of gold nanoparticles, the field enhancement concentrates on the edges of the particle, while the case of amorphous silicon, the electric field has a substantial component inside the particle. Figures 4D,F and 5D,F show that the fields also extend well over half a micron, despite field enhancement around the particles. This finding supports the observation that strong coupling of the SLRs to the dye molecules is possible in thicker films even at 25 mM dye concentration. The simulations were run without the titanium disk beneath the gold nanoparticles, as we found that the titanium does not significantly affect the results (not shown).

4 Discussion

In summary, we have studied light-matter interaction between all-dielectric nanoparticle arrays consisting
of amorphous silicon and organic dye molecules, and compared them to a similar system of gold nanoparticle arrays. We found that the SLRs of the dielectric nanoarrays form strong coupling with the emitters, which has, to our knowledge, not been observed before. We show a linear dependence of the Rabi splitting on the dye molecule concentration. We found Rabi splittings up to 253 and 293 eV for amorphous silicon and gold, respectively. In our work, we used square arrays of cylinders. Recently, Todisco et al. [31] demonstrated that further increases in Rabi splittings can be achieved by using disk dimers with a narrow gap in between. This is due to stronger field localization between disks when the incident light polarization is along the dimer. It would be interesting to explore similar effects in our systems. We also found that the Rabi splitting that was not observed at a concentration of 25 mM and a film thickness of 150 nm can be observed at film thicknesses of around 540 nm. The simulated near-field enhancements were up to a factor of 1200 close to the particles in the case of gold nanoparticles and 400 for amorphous silicon nanoparticles. The simulations showed that the modes extend considerably beyond the particles in the substrate normal direction.

The simulations and measurements generally agreed very well. The SLRs in the measurements were red-shifted by approximately 3 nm with respect to the SLRs in the FDTD simulations. This difference is most likely due to small irregularities in the fabricated arrays and a change in the refractive index introduced by the presence of the dye molecules and the PMMA film.

In our system, the resonances of amorphous silicon nanoarrays showed similar behavior in the strong coupling regime and provided similar linewidths and quality factors for the resonant modes as the gold nanoarrays. However, it has been proposed that dielectric nanostructures could provide much narrower linewidths due to their non-dissipative nature [19]. The linewidths are strongly dependent on the size and shape of the particles [32] as well as on the location of the SLR mode relative to the single particle resonance [26, 33]. The linewidth is strongly related to the lifetime of the mode and therefore plays an important role in coherence phenomena such as lasing. Strongly coupled systems of dielectric nanoarrays can therefore lead to new developments and improvements in lasing applications, for example toward polariton lasers and condensates with lower thresholds.

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Data and materials availability: All data needed to evaluate the conclusions in the paper are present in the paper.

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Supplementary Material: The online version of this article offers supplementary material (https://doi.org/10.1515/nanoph-2019-0371).